Purion M

Industry Leading Energy Efficiency



Purion M: Redefining Medium Current Purity, Precision, and Productivity

- Industry Leading Purity
 - Axcelis proprietary Angular Energy Filter removes all forms of contamination
- Industry Leading Precision
 - Advanced angle control featuring in-situ X & Y measurement and control
 - Constant Focal Length Scanning for superior dopant placement repeatability
- Industry Leading Productivity
 - High Mechanical Throughput > 500wph
 - Industry leading beam currents
 - Broadest energy range (2keV 1MeV)

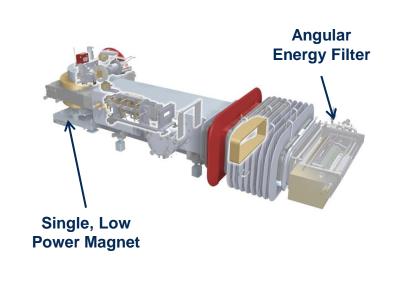




Purion M

Reduced Power Consumption Through Beamline Design

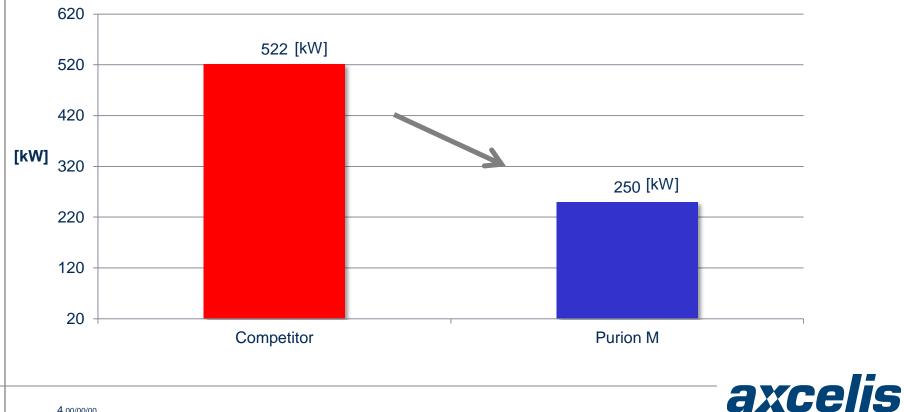
- Top power draw on medium current systems are the high power magnets
 - More magnets = Higher power requirements
- Purion M beam line design utilizing patented Angular Energy Filter reduces number of magnets required
 - AEF utilizes biased plate design → Lower power than magnetic bend, better filter for contamination
- Competitor requires multiple magnetic bends to maintain beam purity and position





Purion M Reduction of >50% in Power Consumed

- Complete Memory Process Flow run, utilizing a full FOUP of wafers for each implant
- Each recipe designed with maximum useable beam current (achieve AT and beam stability) for each system
- Total power measured to complete process flow



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